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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/710,621	07/26/2004	Ming-Lung Huang	11576-US-PA	S-PA 4620	
31561 7	590 10/05/2004		EXAMINER		
JIANQ CHYUN INTELLECTUAL PROPERTY OFFICE			GURLEY, LYNNE ANN		
7 FLOOR-1, N ROOSEVELT	VO. 100 ROAD, SECTION 2		ART UNIT	PAPER NUMBER	
TAIPEI, 100			2812		
TAIWAN			DATE MAILED: 10/05/200	DATE MAILED: 10/05/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

					IXI.			
		Application N	ο. Δ	Applicant(s)				
	081 4-41 0	10/710,621	F	HUANG, MING-LUNG				
Office Action Summary		Examiner	۸	Art Unit				
		Lynne A. Gurle	y 2	812				
Period fe	The MAILING DATE of this communication reply	tion appears on the cov	er sheet with the cor	respondence address				
THE - External control	ORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICA insions of time may be available under the provisions of 3 of SIX (6) MONTHS from the mailing date of this communical period for reply specified above is less than thirty (30) do period for reply specified above, the maximum statutoure to reply within the set or extended period for reply will, reply received by the Office later than three months after the patent term adjustment. See 37 CFR 1.704(b).	TION. 7 CFR 1.136(a). In no event, ho ation. ays, a reply within the statutory or period will apply and will expirely statute, cause the application.	owever, may a reply be timely minimum of thirty (30) days wi ire SIX (6) MONTHS from the n to become ABANDONED (r filed ill be considered timely. mailing date of this communi (35 U.S.C. § 133).	cation.			
Status			•					
1)⊠	Responsive to communication(s) filed of	on 26 July 2004.						
′ —		☐ This action is non-f	inal.					
3)□	<u> </u>							
, —	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposit	ion of Claims							
4)⊠	Claim(s) 1-14 is/are pending in the app	lication.						
,—	4a) Of the above claim(s) is/are withdrawn from consideration.							
5)⊠	Claim(s) 1-7 is/are allowed.							
· · · —	Claim(s) <u>8-14</u> is/are rejected.							
·	Claim(s) is/are objected to.							
· · · · · · · · · · · · · · · · · · ·	Claim(s) are subject to restriction and/or election requirement.							
Applicat	ion Papers							
9) 🗌	The specification is objected to by the E	xaminer.						
· ·	The drawing(s) filed on 26 July 2004 is/s		b) objected to by	the Examiner.				
,—	Applicant may not request that any objectio							
	Replacement drawing sheet(s) including the	÷ , ,	•	, ,	21(d).			
11)	The oath or declaration is objected to by	the Examiner. Note t	he attached Office A	ction or form PTO-15	2.			
Priority :	under 35 U.S.C. § 119							
12)🖾	Acknowledgment is made of a claim for	foreign priority under	35 U.S.C. § 119(a)-(c	d) or (f).				
	☐ All b)☐ Some * c)⊠ None of:		• () (, (,				
•	1.⊠ Certified copies of the priority do	cuments have been re	ceived.					
	2. Certified copies of the priority doe			ı No				
	3. Copies of the certified copies of t		• •		e			
	application from the International	•						
* ;	See the attached detailed Office action for	<u> </u>	* **					
				met Garly				
	· .		DRIMAE	NNE A. GURLEY (/ RY PATENT EXAMINE	R			
Attachmer	et(s)			2800, AU 2812	-			
	ce of References Cited (PTO-892)	4) [Interview Summary (P	TO-413)				
	ce of Draftsperson's Patent Drawing Review (PTO-		Paper No(s)/Mail Date. Notice of Informal Pate	 ent Application (PTO-152)				
	mation Disclosure Statement(s) (PTO-1449 or PT0 er No(s)/Mail Date	5)(SB/08) 5) [6) [an Application (F10-132)				

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DETAILED ACTION

This office action is in response to the application filed 7/26/04.

Currently, claims 1-14 are pending.

Priority

1. Acknowledgment is made of applicant's claim for foreign priority based on an application filed in Taiwan on 7/25/03. It is noted, however, that applicant has not filed a certified copy of the Taiwanese application as required by 35 U.S.C. 119(b).

Specification

1. The specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claim Objections

2. Claims 8-14 are objected to because of the following informalities: In claim 8, line 17, "plurality solder posts" should be "plurality of solder posts". Appropriate correction is required.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

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(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

4. Claims 8-10 and 12-13 are rejected under 35 U.S.C. 102(e) as being anticipated by Chen et al. (US 6,602,775, dated 8/5/03, filed 8/16/01).

Chen shows the method as claimed in figures 1-8 and corresponding text with bonding pad 12, passivation 14 with opening (fig. 1), UBM 16 covering the bonding pad, first photoresist 18 (with lambda 1 sensitivity), second photoresist 20 (with lambda 2 sensitivity), stair-like openings formed in 18 and 20 by an exposure process (figures 3-4), solder material 32 (fig. 5; column 3, lines 35-59) and removal of the photoresists (fig. 6; column 3, lines 60-67) and reflow of the solder (fig. 8; column 4, lines 9-15). The lower opening is smaller than the upper opening (fig. 5). The resist is a dry film and may be spin-coated (column 2, lines 55-67 and column 3, lines 1-35).

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

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1. Determining the scope and contents of the prior art.

- 2. Ascertaining the differences between the prior art and the claims at issue.
- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 7. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
 - 1. Determining the scope and contents of the prior art.
 - 2. Ascertaining the differences between the prior art and the claims at issue.
 - 3. Resolving the level of ordinary skill in the pertinent art.
 - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 8. Claims 11 and 14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chen et al. (US 6,602,775, dated 8/5/03, filed 8/16/01).
- 9. Chen shows the method substantially as claimed and as described in the preceding paragraphs.
- 10. Chen lacks anticipation only in not teaching that the second photoresist has the highest photosensitivity, while the first photoresist has the lowest sensitivity; and that the method of filling the solder material comprises electroplating or stencil printing.
- 11. It would have been obvious to one of ordinary skill in the art to have had the second photoresist have the highest photosensitivity, while the first photoresist has the lowest sensitivity, in the method of Chen, with the motivation that upon exposing the dual photoresist layer, to obtain more accuracy, the lower photoresist could be used as an etch stop for the etch of the second photoresist. Making the exposure determine the selectivity of the etch would be efficient to this end.

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12. It would have been obvious to one of ordinary skill in the art to have had the method of filling the solder material comprise electroplating or stencil printing, in the method of Chen, with the motivation that these are conventional deposition methods for solder for producing quality solder contacts.

Allowable Subject Matter

- 13. Claims 1-7 are allowed.
- 14. The following is a statement of reasons for the indication of allowable subject matter:

 The prior art of record fails to teach or to suggest, either alone or in combination, the steps of:

 "performing a single exposure process to the first and second photoresist layers to form a

 plurality of first openings in the first photoresist layer and a plurality of second openings in the second photoresist layer simultaneously".

Conclusion

15. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. See the PTO Form 892.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lynne A. Gurley whose telephone number is 571-272-1670. The examiner can normally be reached on M-F 7:30-4:00.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on 571-272-1679. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Lynne A. Gurley

Primary Patent Examiner TC 2800, Art Unit 2812

LAG September 30, 2004